

Supplementary Information

Tunable band alignment and large power conversion efficiency in two dimensional InS/ZnIn₂S₄ van der Waals heterostructure

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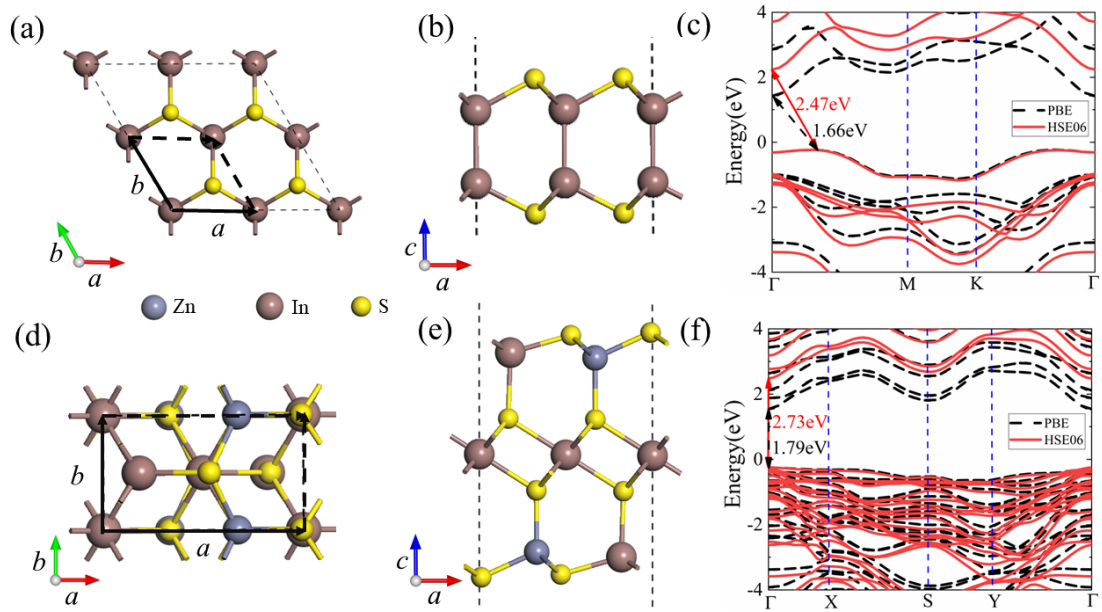


Fig. S1. Top and side views of InS monolayer [(a) and (b)] and ZnIn_2S_4 monolayer [(d) and (e)]. The black line in (a) and (d) indicates the unit cell. The band structures of InS monolayer (c) and ZnIn_2S_4 monolayer (f).

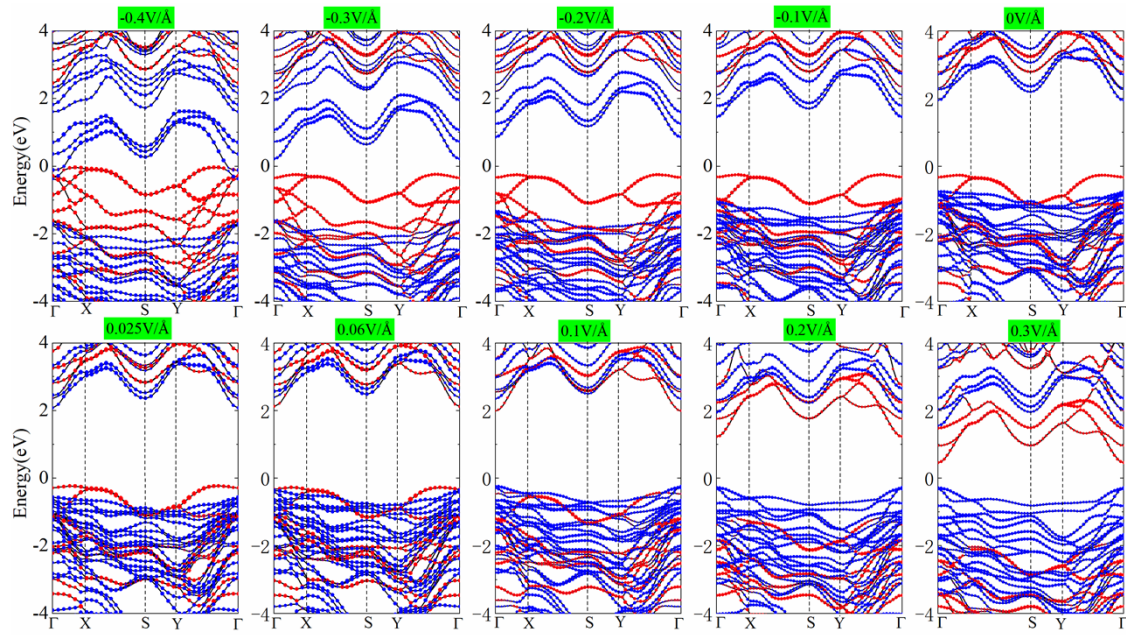


Fig. S2. The projected band structures of the InS/ZnIn₂S₄ heterostructure under electric field ranging from -0.4 to 0.3 V/Å.

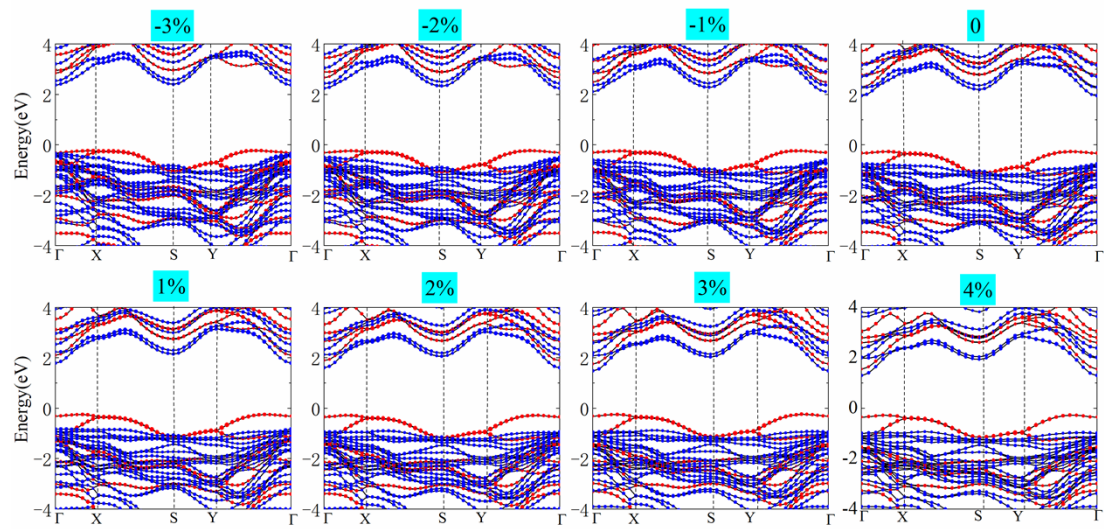


Fig. S3. The projected band structures of InS/ZnIn₂S₄ heterostructure with different biaxial strains. The Fermi levels are set to zero.

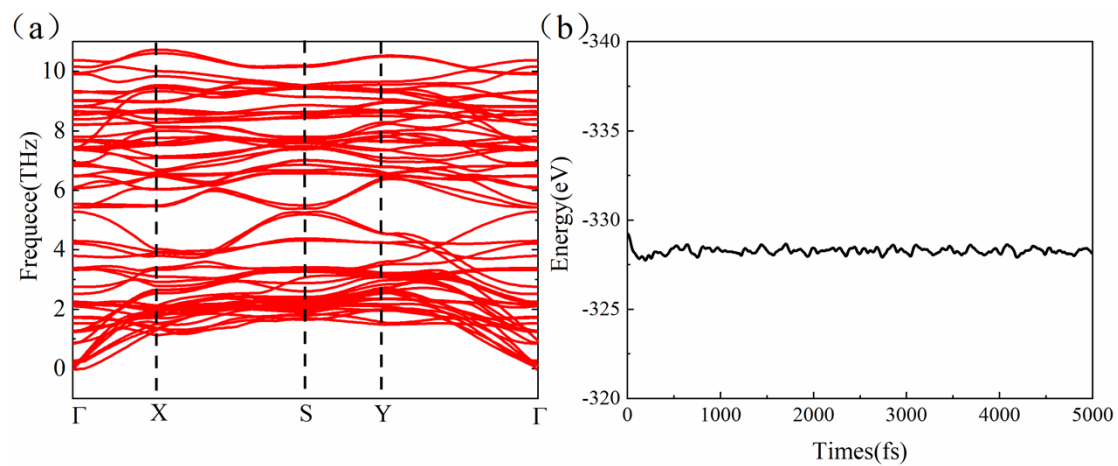


Fig. S4. Phonon spectrums of InS/ZnIn₂S₄ heterostructure (a), the variation of total energy of Ga₂SeTe/In₂SSe (HS1-AB) vdW heterostructures as a function of time at temperature 300 K(b).

Table S1. The calculated lattice constants (a and b), equilibrium interlayer distance (d), and binding energy (E_b) of the InS/ZnIn₂S₄ heterostructures with different stacking configuration.

	$a(\text{\AA})$	$b(\text{\AA})$	$d(\text{\AA})$	$E_b(\text{meV})$
AA	6.796	3.929	3.71	-25.1
AB	6.796	3.928	3.77	-14.9
AC	6.795	3.926	4.19	-9.6
AD	6.795	3.928	4.03	-11.7

Table S2. The calculated η of the InS/ZnIn₂S₄ heterostructure under different electric field E_{\perp} . The relevant parameters for the η , E_g^d , J_{sc}/P_{solar} , ΔE_c , and V_{oc} , are also provided.

E_{\perp}	E_g^d	J_{sc}/P_{solar}	ΔE_c [eV]	V_{oc} [V]	$\eta(\%)$
-0.3	2.63	0.078	2.17	0.16	0.81
-0.2	3.02	0.032	1.91	0.81	1.68
-0.1	2.61	0.081	0.90	1.41	7.42
0	2.57	0.087	0.36	1.91	10.80
0.025	2.59	0.085	0.28	2.01	11.10
0.1	2.60	0.082	0.37	1.93	10.29
0.2	2.24	0.155	0.73	1.21	12.19
0.3	1.84	0.245	1.09	0.45	7.17

Table S3. The calculated η of the InS/ZnIn₂S₄ heterostructure under different biaxial strains ε . The relevant parameters for the η , E_g^d , J_{sc}/P_{solar} , ΔE_c , and V_{oc} , are also provided.

$\varepsilon(\%)$	E_g^d [eV]	J_{sc}/P_{solar}	ΔE_c [eV]	V_{oc} [V]	$\eta(\%)$
-3	3.07	0.028	0.47	2.30	4.18
-2	2.90	0.042	0.43	2.17	5.92
-1	2.73	0.065	0.38	2.05	8.66
0	2.57	0.087	0.36	1.91	10.80
1	2.35	0.127	0.32	1.73	14.28
2	2.18	0.163	0.30	1.58	16.74
3	2.00	0.205	0.28	1.42	18.92
4	1.83	0.252	0.26	1.27	20.80

Table S4. Calculated carrier effective mass (m^*), deformation potential constant (E_l), and carrier mobility (μ) for electron (e) and hole (h) along the zigzag (x) and armchair (y) directions at 300 K in InS/ZnIn₂S₄ heterostructure

Carrier type	$m_x^*(m_0)$	$m_y^*(m_0)$	$E_{lx}(eV)$	$E_{ly}(eV)$	μ_x (cm ² V ⁻¹ s ⁻¹)	μ_y (cm ² V ⁻¹ s ⁻¹)
Electron	1.49	1.28	-8.35	-8.72	2091.06	2231.94
Hole	0.9	1.01	-9.28	-7.00	3481.04	6118.01